

SPECIFICATION

TITLE OF THE INVENTION

Method and device for discharging surface treatment

5

TECHNICAL FIELD

The present invention in general relates to a discharging surface treatment method by which a discharge is generated between an electrode and a treatment target so that a hard coat film is formed on the surface of the treatment target by the discharging energy. This invention relates to an improvement in the discharging surface treatment method and the device used to realized this method.

15 BACKGROUND ART

Conventionally, with respect to a technique for coating the surface of a treatment target so as to provide corrosion resistant property and abrasion resistant property, for example, Japanese Patent Application Laid-Open (JP-A) No. 5-148615 has disclosed a discharging surface treatment method. In this technique, a primary treatment (deposition treatment) is carried out by using a green compact electrode made from WC powder and Co powder, etc., and after exchanging this to an electrode that is comparatively less susceptible to electrode consumption,

25

09872421.053101

such as a copper electrode, a secondary treatment (re-fusing treatment) is then carried out. Thus, this surface treatment method for a metal material is constituted by the two processes. This conventional technique provides a superior method for forming a hard coat film having a thickness of approximately several tens of μm on a steel plate. However, a problem with this technique is that it is difficult to form a hard coat film having high adhering strength onto a sintered material such as an ultra-hard alloy.

Next, referring to Fig. 7, an explanation will be given of a discharging surface treatment method for forming a hard coat film having high adhering strength even to an ultra-hard alloy that is disclosed by Japanese Patent Application Laid-Open (JP-A) No. 9-192937. Reference number 1 represents a green compact electrode formed by compressing and molding TiH_2 , and reference number 2 represents a treatment target. Reference number 3 represents a treatment vessel, and reference number 4 represents a treatment solution. Reference number 5 represents a switching element for switching voltage and current to be applied to the green compact electrode 1 and the treatment target 2. Reference number 6 represents a control circuit for controlling ON-OFF of the switching element 5, and reference number 7 represents a power supply. Reference

09872421.053101

number 8 represents a resistor, and reference number 9 represents a hard coat film that has been formed. By using a discharging surface treatment having such an arrangement, it is possible to form a hard coat film having a thickness of approximately several μm to several tens of μm on the surface of steel or ultra-hard alloy.

Moreover, Japanese Patent Application Laid-Open (JP-A) No. 10-225824 has disclosed a method in which: a material that generates a highly hard carbide, such as Ti, V, Nb and Ta, is used as an electrode to generate a discharge so that the surface of the treatment target is decarbonated to have a slightly rough surface (pre-treatment), and a discharge is generated by using a TiH_2 -type green compact electrode so as to carry out a surface treatment (main treatment) on the treatment target. This pre-treatment is carried out so as to provide easy adhesion of the coating material in the main treatment. Moreover, for the same purpose as this, another method has been disclosed in which: a pre-treatment is carried out under a condition where the TiH_2 -type green compact electrode has a negative polarity with a comparatively small discharging energy, and the same TiH_2 -type green compact electrode with higher discharging energy is then used so as to carry out the main treatment.

Any of the above-mentioned conventional techniques features that a green compact electrode is used. However,

09872421.053101

for the following three reasons, it is difficult to put these into practical use.

First, it is difficult to mold an electrode having a size suitable for practical use. In other words, in order to mold the electrode so as to have a size suitable for practical use in the surface treatment for a metal mold, etc., the capability of the pressing device has to be extremely increased, and since upon compressing and molding powder material, a pressure is not uniformly transmitted to the inside of the material to cause unevenness in the density, resulting in defects such as cracks. Moreover, the green compact electrode thus formed is susceptible to collapse in shape, making it difficult to apply this to the secondary treatment, and variations occur in the hard coat film to be formed on the treatment target, resulting in degradation in the quality.

Second, difficulty in dealing with the electrode material. In other words, powder of Ti and TiH_2 is susceptible to oxidation, and in particular, TiH_2 tends to change with time, that is, to cause hydrolysis even in the air, resulting in difficulty in dealing therewith. Moreover, when put into water, it generates hydrogen gas violently, raising a problem in dealing with waste electrodes.

Third, difficulty in providing a thick film. In other

09872421.053101

words, the conventional methods are only allowed to form a thickness in the range of several μm to several tens μm , and fail to form a hard coat film having a thickness exceeding this thickness that is required from the industrial point of view.

The third reason is explained in more detail below. The formation of a thin-film has been widely carried out by physical vapor deposition and chemical vapor deposition, etc., which are dry processes. However, the formation of a thick-film is hardly carried out by these methods, and at present, it has to be carried out by using a flame coating method, etc. The flame coating method builds up various materials on a treatment target, but the structure is coarse, with the result that it is not suitable for the application such as a coat film on a metal mold that requires precision and durability, and it also has many limitations to materials to be applied.

DISCLOSURE OF THE INVENTION

It is an object of this invention to provide a discharging surface treatment method and a device for such a method, which can effectively form a hard coat film on a treatment target, and easily mold an electrode, as well as forming a thick film of a hard coat film within a desired area range, and which is also suitable for various machine

parts such as metal molds, tools and machine essential parts.

~~SUB B₁ In the discharging surface treatment method according~~
to a first aspect of this invention, a powder that is formed

by a simple substance or a combination of a plurality of
5 carbides of metals belonging to the IVa, Va and VIa families
in the Periodic Table is mixed ferrous-family metal powder
or non-ferrous metal powder having the same composition as
the treatment target as a simple substance or a combination
of a plurality of metals, and this is compressed and molded,
10 and then preliminarily sintered to form a sintered electrode
serving as a discharge processing electrode, and the
electrical conditions at the time when the base member of
the treatment target is directly subjected to a discharging
surface treatment and the electrical conditions at the time
15 when a hard coat film that has been formed is subjected to
a discharging surface treatment are altered according to
the characteristics of the treatment target material.

~~SUB B₂ In the discharging surface treatment method according~~
to a second aspect of this invention, a powder that is formed

20 by a simple substance or a combination of a plurality of
carbides of metals belonging to the IVa, Va and VIa families
in the Periodic Table is mixed ferrous-family metal powder
or non-ferrous metal powder having the same composition as
the treatment target as a simple substance or a combination
25 of a plurality of metals, and this is compressed and molded,

09872421.053101

and then preliminarily sintered to form a sintered electrode
serving as a discharge processing electrode, and the
electrical conditions at the time when a hard coat film that
has been formed is subjected to a discharging surface
5 treatment are altered at least once according to the
characteristics of the treatment target material.

sub 3 1 In the discharging surface treatment method according
to a third aspect of this invention, a powder that is formed
by a simple substance or a combination of a plurality of
10 carbides of metals belonging to the IVa, Va and VIa families
in the Periodic Table is mixed ferrous-family metal powder
or non-ferrous metal powder having the same composition as
the treatment target as a simple substance or a combination
of a plurality of metals, and this is compressed and molded,
15 and then preliminarily sintered to form a sintered electrode
serving as a discharge processing electrode, and the
electrical conditions at the time when the base member of
the treatment target is directly subjected to a discharging
surface treatment and the electrical conditions at the time
20 when a hard coat film that has been formed is subjected to
a discharging surface treatment are altered according to
the characteristics of the treatment target material, while
the electrical conditions at the time when the hard coat
film that has been formed is subjected to a discharging
25 surface treatment are altered at least once according to

09872421-053101

~~the characteristics of the treatment target material.~~

~~sup 2/4) In the discharging surface treatment method according to a fourth aspect of this invention, in the configuration according to the first aspect of this invention, it is preferable that an inert gas is interpolated between the sintered electrode and the treatment target.~~

~~sup 2/5) In the discharging surface treatment method according to a fifth aspect of this invention, in the configuration according to the second aspect of this invention, it is preferable that an inert gas is interpolated between the sintered electrode and the treatment target.~~

~~sup 2/6) In the discharging surface treatment method according to a sixth aspect of this invention, in the configuration according to the third aspect of this invention, it is preferable that an inert gas is interpolated between the sintered electrode and the treatment target.~~

~~sup 2/7) In the discharging surface treatment method according to a seventh aspect of this invention, in the configuration according to the first aspect of this invention, it is preferable that the sintered electrode is allowed to scan the treatment target so that the hard coat film is formed on the surface of the treatment target.~~

~~sup 2/8) In the discharging surface treatment method according to a eighth aspect of this invention, in the configuration according to the second aspect of this invention, it is~~

09872421.053101

~~preferable that the sintered electrode is allowed to scan the treatment target so that the hard coat film is formed on the surface of the treatment target.~~

^{Sub 9}~~In the discharging surface treatment method according to a ninth aspect of this invention, in the configuration according to the third aspect of this invention, it is preferable that the sintered electrode is allowed to scan the treatment target so that the hard coat film is formed on the surface of the treatment target.~~

^{Sub 10}~~In the discharging surface treatment device according to a tenth aspect of this invention, a powder that is formed by a simple substance or a combination of a plurality of carbides of metals belonging to the IVa, Va and VIa families in the Periodic Table is mixed ferrous-family metal powder or non-ferrous metal powder having the same composition as the treatment target as a simple substance or a combination of a plurality of metals, and this is compressed and molded, and then preliminarily sintered to form a sintered electrode serving as a discharge processing electrode. Moreover, the above-mentioned device is provided with a switching unit which alters the electrical conditions at the time when the base member of the treatment target is directly subjected to a discharging surface treatment and the electrical conditions at the time when a hard coat film that has been~~

25 ~~formed is subjected to a discharging surface treatment~~

09872421.053101

~~according to the characteristics of the treatment target material.~~

³⁰⁶
_{B5} ~~In the discharging surface treatment device according~~
to an eleventh aspect of this invention, a powder that is
5 formed by a simple substance or a combination of a plurality
of carbides of metals belonging to the IVa, Va and VIa families
in the Periodic Table is mixed ferrous-family metal powder
or non-ferrous metal powder having the same composition as
the treatment target as a simple substance or a combination
10 of a plurality of metals, and this is compressed and molded,
and then preliminarily sintered to form a sintered electrode
serving as a discharge processing electrode. Moreover, the
device is provided with a switching unit which alters the
electrical conditions at the time when a hard coat film that
15 has been formed is subjected to a discharging surface
treatment at least once according to the characteristics
of the treatment target material.

³⁰⁶
_{B6} ~~In the discharging surface treatment device according~~
to a twelfth aspect of this invention, a powder that is formed
20 by a simple substance or a combination of a plurality of
carbides of metals belonging to the IVa, Va and VIa families
in the Periodic Table is mixed ferrous-family metal powder
or non-ferrous metal powder having the same composition as
the treatment target as a simple substance or a combination
25 of a plurality of metals, and this is compressed and molded,

09872421-053101

and then preliminarily sintered to form a sintered electrode serving as a discharge processing electrode. Moreover, the above-mentioned device is provided with a first switching unit which alters the electrical conditions at the time when the base member of the treatment target is directly subjected to a discharging surface treatment and the electrical conditions at the time when a hard coat film that has been formed is subjected to a discharging surface treatment according to the characteristics of the treatment target material, and a second switching unit which alters the electrical conditions at the time when the hard coat film that has been formed is subjected to a discharging surface treatment at least once according to the characteristics of the treatment target material.

15 ^{sub 13} In the discharging surface treatment device according to a thirteenth aspect of this invention, in the configuration according to the tenth aspect of this invention, it is preferable that an inert-gas supplying unit is installed so as to interpolate an inert gas between the sintered electrode and the treatment target.

20 ^{sub 14} In the discharging surface treatment device according to a fourteenth aspect of this invention, in the configuration according to the eleventh aspect of this invention, it is preferable that an inert-gas supplying unit is installed so as to interpolate an inert gas between the

09872421.053101

~~sintered electrode and the treatment target.~~

306/13 ~~In the discharging surface treatment device according~~
to a fifteenth aspect of this invention, in the configuration
according to the twelfth aspect of this invention, it is
5 preferable that an inert-gas supplying unit is installed
so as to interpolate an inert gas between the sintered
~~electrode and the treatment target.~~

306/16 ~~In the discharging surface treatment device according~~
to a sixteenth aspect of this invention, in the configuration
10 according to the tenth aspect of this invention, it is
preferable that an X-axis driving device, a Y-axis driving
device and a Z-axis driving device, which relatively shift
the sintered electrode and the treatment target in the
X-direction, Y-direction and Z-direction, are installed so
15 that the X-axis driving device, the Y-axis driving device
and the Z-axis driving device allow the sintered electrode
to scan the treatment target to form the hard coat film on
~~the surface of the treatment target.~~

306/17 ~~In the discharging surface treatment device according~~
20 to a seventeenth aspect of this invention, in the
configuration according to the eleventh aspect of this
invention, it is preferable that an X-axis driving device,
a Y-axis driving device and a Z-axis driving device, which
relatively shift the sintered electrode and the treatment
25 ~~target in the X-direction, Y-direction and Z-direction, are~~

09072421.053101

~~installed so that the X-axis driving device, the Y-axis driving device and the Z-axis driving device allow the sintered electrode to scan the treatment target to form the hard coat film on the surface of the treatment target.~~

5 ~~sub 18~~ ~~In the discharging surface treatment device according to a eighteenth aspect of this invention, in the configuration according to the twelfth aspect of this invention, it is preferable that an X-axis driving device, a Y-axis driving device and a Z-axis driving device, which~~
 10 ~~relatively shift the sintered electrode and the treatment target in the X-direction, Y-direction and Z-direction, are installed so that the X-axis driving device, the Y-axis driving device and the Z-axis driving device allow the sintered electrode to scan the treatment target to form the~~
 15 ~~hard coat film on the surface of the treatment target.~~

Since the present invention has the above-mentioned arrangement, the following effects are obtained.

The discharging surface treatment method according to any one of the first to third aspects makes it possible
 20 to easily form an electrode and also to form a hard coat film having high adhesion to the treatment target efficiently. Therefore, the discharging surface treatment method is applicable to various machine parts such as molds, tools and machine constituent parts. Moreover, the hard coat film
 25 is allowed to deposit on the treatment target with an area

09872421.053101

virtually equal to the area of the electrode, thereby making it possible to eliminate the need of a masking treatment.

The discharging surface treatment method according to the fourth aspect has such an effect in addition to the effects of the first aspect that the structure is simplified.

The discharging surface treatment method according to the fifth aspect has such an effect in addition to the effects of the second aspect that the structure is simplified.

The discharging surface treatment method according to the sixth aspect has such an effect in addition to the effects of the third aspect that the structure is simplified.

~~308/19~~ In addition to the effects of the first aspect, the discharging surface treatment method according to the seventh aspect makes it possible to use a small-size sintered electrode, and the process is carried out with this electrode being allowed to scan. Therefore, it is not necessary to use a large-size sintered electrode having a specific shape, and it is possible to form a hard coat film with the small-size sintered electrode being allowed to scan on the entire curved face of the treatment target, such as a mold, having a three-dimensional free curved face, so as to have a uniform thickness over the entire area or a varied film thickness, if necessary.

~~308/20~~ In addition to the effects of the second aspect, the

09872421.053101

discharging surface treatment method according to the eighth aspect makes it possible to use a small-size sintered electrode, and the process is carried out with this electrode being allowed to scan. Therefore, it is not necessary to use a large-size sintered electrode having a specific shape, and it is possible to form a hard coat film with the small-size sintered electrode being allowed to scan on the entire curved face of the treatment target, such as a mold, having a three-dimensional free curved face, so as to have a uniform thickness over the entire area or a varied film thickness, if necessary.

~~Sub 21~~ In addition to the effects of the third aspect, the discharging surface treatment method according to the ninth aspect makes it possible to use a small-size sintered electrode, and the process is carried out with this electrode being allowed to scan. Therefore, it is not necessary to use a large-size sintered electrode having a specific shape, and it is possible to form a hard coat film with the small-size sintered electrode being allowed to scan on the entire curved face of the treatment target, such as a mold, having a three-dimensional free curved face, so as to have a uniform thickness over the entire area or a varied film thickness, if necessary.

The discharging surface treatment device according to any one of the tenth to twelfth aspects makes it possible

09372421-053101
T01250-1242860

to easily form an electrode and also to form a hard coat
 film having high adhesion to the treatment target efficiently.
 Therefore, the discharging surface treatment method is
 applicable to various machine parts such as molds, tools
 5 and machine constituent parts. Moreover, the hard coat film
 is allowed to deposit on the treatment target with an area
 virtually equal to the area of the electrode, thereby making
 it possible to eliminate the need of a masking treatment.

The discharging surface treatment device according
 10 to the thirteenth aspect has such an effect in addition to
 the effects of the tenth aspect that the structure is
 simplified.

The discharging surface treatment device according
 to the fourteenth aspect has such an effect in addition to
 15 the effects of the eleventh aspect that the structure is
 simplified.

The discharging surface treatment device according
 to the fifteenth aspect has such an effect in addition to
 the effects of the twelfth aspect that the structure is
 20 simplified.

^{308/27} ~~In addition to the effects of the tenth aspect, the~~
 discharging surface treatment device according to the
 sixteenth aspect makes it possible to use a small-size
 sintered electrode, and the process is carried out with this
 25 ~~electrode being allowed to scan. Therefore, it is not~~

09872421.053101

~~necessary to use a large-size sintered electrode having a~~
 specific shape, and it is possible to form a hard coat film
 with the small-size sintered electrode being allowed to scan
 on the entire curved face of the treatment target, such as
 5 a mold, having a three-dimensional free curved face, so as
 to have a uniform thickness over the entire area or a varied
 film thickness, if necessary.

308/23/ In addition to the effects of the eleventh aspect,
 the discharging surface treatment method according to the
 10 seventeenth aspect makes it possible to use a small-size
 sintered electrode, and the process is carried out with this
 electrode being allowed to scan. Therefore, it is not
 necessary to use a large-size sintered electrode having a
 specific shape, and it is possible to form a hard coat film
 15 with the small-size sintered electrode being allowed to scan
 on the entire curved face of the treatment target, such as
 a mold, having a three-dimensional free curved face, so as
 to have a uniform thickness over the entire area or a varied
 film thickness, if necessary.

308/24/ In addition to the effects of the twelfth aspect, the
 discharging surface treatment method according to the
 eighteenth aspect makes it possible to use a small-size
 sintered electrode, and the process is carried out with this
 electrode being allowed to scan. Therefore, it is not
 25 ~~necessary to use a large-size sintered electrode having a~~

09872421.053101

~~specific shape, and it is possible to form a hard coat film with the small-size sintered electrode being allowed to scan on the entire curved face of the treatment target, such as a mold, having a three-dimensional free curved face, so as to have a uniform thickness over the entire area or a varied film thickness, if necessary.~~

BRIEF DESCRIPTION OF THE DRAWINGS

09872421.053101
10 Fig. 1 is a structural drawing that shows a discharging surface treatment method and a device for such a method according to a first embodiment of the present invention; Fig. 2 is a drawing that shows a state in which a hard coat film is deposited by continuous discharging in the discharging surface treatment method and the device thereof
15 according to the first embodiment the present invention; Fig. 3 is a drawing that shows a state in which a thick film is formed in the discharging surface treatment method and the device thereof according to the first embodiment of the present invention; Fig. 4 is a drawing that shows a switching
20 unit for altering electrical conditions in the discharging surface treatment method and the device thereof according to the first embodiment the present invention; Fig. 5 is a structural drawing that shows a discharging surface treatment method and a device for such a method according
25 to a second embodiment of the present invention; Fig. 6 is

a structural drawing that shows a discharging surface treatment method and a device for such a method according to a third embodiment of the present invention; and Fig. 7 is a structural drawing that shows a conventional surface treatment method.

BEST MODE FOR CARRYING OUT THE INVENTION

FIRST EMBODIMENT

Fig. 1 is a structural drawing that shows a discharging surface treatment method and a device for such a method according to a first embodiment of the present invention. Reference number 2 represents a treatment target, and reference number 3 represents a processing vessel. Reference number 4 represents a processing fluid, such as insulating oil or water. Reference number 10 represents a shifting motor, and reference number 11 represents a shifting thread. Reference number 12 represents a sintered electrode, and reference number 13 represents a hard coat film formed on the treatment target 2. Reference number 14 represents a control device, provided with a power supply, for controlling a current and a voltage. The shifting motor 10, controlled by a controlling system not shown, is designed so that the sintered electrode 12 is shifted toward the treatment target 2 in a desired control mode, such as a servo-shifting mode and a constant-shifting mode, through

09872421.053101
T01550.1242860

~~the shifting thread 11.~~

As mentioned-above, the processing fluid 4 is insulating oil or water. Following advantages are obtained when the insulating oil is used. That is, conventional techniques of discharge processing devices that have been widely used are applicable, as they are, and a comparatively simple structure is available. On the other hand, if water is used, in some cases, hydroxides may be generated simultaneously as the reaction takes place, resulting in a problem when a high-quality coat film is required. However, in the case of the application of a non-electrolytic power supply in a wire discharge processing device that has been widely used at present, the above-mentioned disadvantage is reduced to a minimum so that even water is used as the processing fluid, it becomes possible to form a hard coat film having virtually the same characteristics as that produced by using an insulating oil as the processing fluid from the viewpoint of practical use.

³²
~~B₂ 27~~ ~~A method of manufacturing the sintered electrode 12~~
will now be explained. A powder that is formed by a simple substance or a combination of a plurality of carbides of metals belonging to the IVa, Va and VIa families in the Periodic Table (for example, WC, TiC, TaC, etc.) is mixed ferrous-family metal powder such as Fe, Co and Ni, or non-ferrous metal powder having the same composition as the

09872421.053101

00072421.053101

~~treatment target (for example, Al alloy powder, etc.) as~~
a simple substance or in combination, and this is compressed
and molded into a predetermined shape, thereby manufacturing
a green compact electrode. Then, this is put into a vacuum
5 furnace, etc., and the temperature inside the furnace is
gradually increased so as to harden the green compact
electrode to a degree, for example, approximately as hard
as chalk so that it has sufficient strength to withstand
a mechanical machining process and also is not hardened too
10 much (this process is referred to as "preliminary sintering
process"). In this state, the ferrous-family metal such
as Co starts to elute to be buried in gaps between carbides,
thereby forming a so-called solid solution. In contrast,
at contact portions between the carbides, although mutual
15 bonding progresses, the bonding is weak because the sintering
temperature is comparatively low with the result that a main
sintering process is not attained. The sintered electrode
in this state, which has been subjected to the preliminary
sintering process, is taken out, and machined and sized to
20 a predetermined shape. Thus, this is used as the sintered
electrode 12.

²⁰²₂₁ ~~The conditions of the above-mentioned preliminary~~
sintering process are different depending on electrode
materials. However, this is determined preliminarily
25 ~~through experiments. For example, the sintering.~~

~~temperature is set approximately in the range of 400 to 1100 degree centigrade.~~

^{SUB}
~~14~~ In this case, it is essential not to raise the preliminary sintering temperature to approximately not less than 1100 degree centigrade. The temperatures exceeding this temperature make the electrode too hard, resulting in a problem in which in the next discharging process, the electrode material comes off irregularly due to a thermal impact caused by arc discharging, failing to properly supply discharging between the electrodes, resulting in serious adverse effects to the quality of the coat film formed on the treatment target.

^{SUB}
~~14~~ Next, an explanation will be given of a formation method of the hard coat film 13. When an arc discharge is generated intermittently or continuously between the sintered electrode 12 and the treatment target 2, the pole-to-pole gap has a high temperature locally due to arc heat. First, when an arc discharge is generated once, one portion of the electrode material comes off between the poles, and is simultaneously discharged in a powdered state by the thermal impact energy at portions of the sintered electrode 12 preliminarily sintered facing the treatment target 2. Since the pole-to-pole gap enters a high-temperature plasma state of not less than several thousands of degree centigrade momentarily, most portions of the electrode material are

09872421.053101

completely fused. The surface of the treatment target facing the electrode is also heated instantaneously at the generation position of the arc discharge, and fused in the same manner as the electrode material. At this high-temperature state, the fused electrode material and the treatment target are mutually mixed with each other to form an alloy phase between the electrode material and the treatment target on the treatment target. Next, since the processing fluid is located in the pole-to-pole gap and in the vicinity thereof, this is abruptly cooled off, and during a cooling phase from the high-temperature state, an interface reaction between the liquid phase of the ferrous-family metal and the solid phase of the carbides or a solid-solution forming reaction between the solid phases of the carbides instantaneously occurs, thereby executing a main sintering process in an extremely short time. In this manner, a hard coat film 13 is formed on the treatment target 2. When this process is repeated, the deposition of the coat film progresses as the time elapses, thereby making it possible to form a thick film.

Fig. 2 shows a state in which the hard coat film is depositing due to continuous discharges. It can be clearly seen that the hard coat films, each formed by a single discharge, are allowed to deposit in a folded manner.

Fig. 3 shows a state in which a thick film is formed

A30

and a discharge current at this time. WC-Co is used as the
sintered electrode 12 and a steel plate is used as the
treatment target 2. Moreover, Fig. 3(a) shows a case in
which a discharge is directly applied to the base member
5 of the treatment target 2, and Fig. 3(b) shows a case in
which, after a hard coat film 13 has been formed, a discharge
is further applied thereto. Depending on the cases in which
a discharge is directly applied to the base member of the
treatment target 2 and in which a discharge is applied after
10 the hard coat film 13 has been formed, electrical conditions
including the discharge current value I_p , the discharge
current pulse width τ_p and the pause time τ_r are properly
altered so as to fit to the characteristics of the subject
material. Moreover, depending on cases, the poles of the
15 electrode are also changed. This is because the base member
and the hard coat film formed later are respectively
different in material characteristics and hardness.
Therefore, the electrical conditions are altered so as to
fit to the characteristics of the subject material depending
20 on the cases in which a discharge is directly applied to
the base member and in which a discharge is further applied
after the hard coat film has been formed so as to fit to
the characteristics of the subject material; consequently,
the electrical conditions suitable for the corresponding
25 subject material are adopted so that it becomes possible

09872421.053101

to carry out the process in a shorter time, and also to form
a hard coat film with high adhesion. Such electrical
conditions suitable for the respective characteristics of
the subject materials are preliminarily determined through
5 experiments, etc., and the control device 14 alters these
according to the characteristics of the subject material.
For example, the alteration of each of the discharging
current value I_p , the discharging current pulse width τ_p
and the pause time τ_r is carried out by switching operations
10 of switches 15 and 16 and the controlling operations of the
switching in the control circuit shown in Fig. 4.

Moreover, the above description has shown a case in
which the electrical conditions are altered depending on
the cases in which a discharge is directly applied to the
15 base member and in which a discharge is further applied after
the hard coat film has been formed. However, even in the
course of formation of a thick, hard coat film, the electrical
conditions may be altered according to the characteristics
of the subject material.

20 Moreover, in Fig. 4, two switches are used for the
switching operations. However, three or more switches may
be used. Moreover, any means that can alter the current,
such as a variable resistor for changing a current, may be
used.

25 Moreover, Fig. 3 has exemplified a case in which a

09872421-053101
T07E50-7242360

steel plate is used as the base member of the treatment target. However, when the base member is made of a cemented carbide, Ti-based materials may be used as the electrode. The current waveform is altered in response to various combinations
 5 between such treatment target materials and the electrodes.

SECOND EMBODIMENT

³⁰³₂ 31 Fig. 5 is a structural drawing that shows a discharging
 surface treatment method and a device for such a method according to a second embodiment of the present invention.
 10 Reference number 2 represents a treatment target, and reference number 12 represents a sintered electrode. Reference number 13 represents a hard coat film formed on the treatment target 2. Reference number 14 represents a control device, provided with a power supply, for controlling
 15 a current and a voltage. The hard coat film 13 is formed on the surface of the treatment target 2 while the sintered electrode 12 and the treatment target 2 are relatively shifted in the X-direction, Y-direction and Z-direction by using an X-axis driving device, a Y-axis driving device and
 20 a Z-axis driving device, not shown. For example, when the treatment target 2 is a mold, its surface is not a plane face, and has a three-dimensional shape with complex free curved faces. However, the X-axis driving device, the Y-axis driving device and the Z-axis driving device allow
 25 the sintered electrode 12 to scan along the free curved face

09872421.053101

of the mold with the gap being maintained constant or the servo-voltage being maintained constant. In this case, since the electrode is consumed very quickly, a compensating shifting operation is required for compensating for the electrode consumption. Therefore, the movement control of the main axis for supporting the electrode in the Z-axis direction needs to be carried out accurately and quickly. The above-mentioned operations are repeated so that the electrode is allowed to scan all over the curved faces constituting the mold. Thus, it becomes possible to deposit the hard coat film over the entire area uniformly, or with a varied film thickness, if necessary.

Moreover, when a discharge is directly applied to the base member of the treatment target and when a discharge is further applied after the hard coat film has been formed, or in the course of formation of the thick, hard coat film, the electric conditions are altered so as to fit to the characteristics of the subject treatment material, that is, the electric conditions suitable for the subject treatment material are adopted. Thus, it becomes possible to carry out the process in a shorter time, and also to form a hard coat film with high adhesion.

THIRD EMBODIMENT

³⁰⁸₃₂ Fig. 6 is a structural drawing that shows a discharging surface treatment method and a device for such a method.

09872421-053101

³² ~~according to a third embodiment of the present invention.~~
This embodiment explains a discharging operation performed
in the environment of gas. Reference number 2 represents
a treatment target. Reference number 10 represents a
5 shifting motor, and reference number 11 represents is a
shifting thread. Reference number 12 represents a sintered
electrode, and reference number 13 represents a hard coat
film formed on the treatment target 2. Reference number
14 represents a control device, provided with a power supply,
10 for controlling a current and a voltage. Reference number
17 represents a gas supply source, and reference number 18
represents a path and 19 is a supply pipe. The gas supply
source 17 is connected to the path 18 installed inside the
sintered electrode 12 through a pipe. While power is
15 supplied by the power supply of the control device 14, inert
gas, such as air or nitrogen gas, is supplied at a
predetermined amount from the gas supply source 17. The
supply pipe 19 is used for supplying gas from the outside
of the electrode when a path is not formed inside the electrode,
20 and in this case, gas is discharged toward the pole-to-pole
gap. The objects of the gas supply are to cool off the
pole-to-pole gap and to transport excessive electrode
materials out of the system, and these object are the same
as those of the processing fluid. Without the gas supply,
25 ~~it is difficult to form the hard coat film on the treatment~~

~~target in a stable manner. With respect to the kinds of~~
gases, air or nitrogen gas is suitable from the environmental
point of view.

In the gaseous discharging operation of this type also,
5 when a discharge is directly applied to the base member of
the treatment target and when a discharge is further applied
after the hard coat film has been formed, or in the course
of formation of the thick, hard coat film, the electric
conditions are altered so as to fit to the characteristics
10 of the subject treatment material, that is, the electric
conditions suitable for the subject treatment material are
adopted. Thus, it becomes possible to carry out the process
in a shorter time, and also to form a hard coat film with
high adhesion.

15

INDUSTRIAL APPLICABILITY

As described above, the discharging surface treatment
method and the device thereof according to the present
invention is suitable for formation of a hard coat film on
20 a treatment target.

09872421-053101
FOI 50-1242860